

Tunneling Hot Spots in Ferroelectric SrTiO₃

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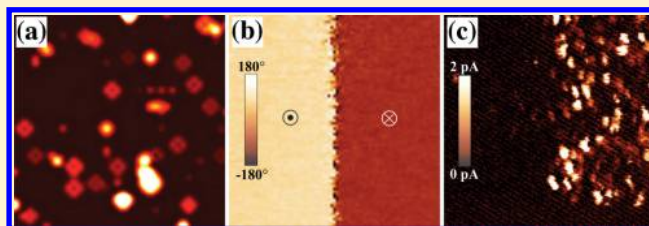
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S Supporting Information

ABSTRACT: Strontium titanate (SrTiO₃) is the “silicon” in the emerging field of oxide electronics. While bulk properties of this material have been studied for decades, new unexpected phenomena have recently been discovered at the nanoscale, when SrTiO₃ forms an ultrathin film or an atomically sharp interface with other materials. One of the striking discoveries is room-temperature ferroelectricity in strain-free ultrathin films of SrTiO₃ driven by the Ti_{Sr} antisite defects, which generate a local dipole moment polarizing the surrounding nanoregion. Here, we demonstrate that these polar defects are not only responsible for ferroelectricity, but also propel the appearance of highly conductive channels, “hot spots”, in the ultrathin SrTiO₃ films. Using a combination of scanning probe microscopy experimental studies and theoretical modeling, we show that the hot spots emerge due to resonant tunneling through localized electronic states created by the polar defects and that the tunneling conductance of the hot spots is controlled by ferroelectric polarization. Our finding of the polarization-controlled defect-assisted tunneling reveals a new mechanism of resistive switching in oxide heterostructures and may have technological implications for ferroelectric tunnel junctions. It is also shown that the conductivity of the hot spots can be modulated by mechanical stress, opening a possibility for development of conceptually new electronic devices with mechanically tunable resistive states.

KEYWORDS: Strontium titanate, resistive switching, ferroelectric, tunnel junctions



Control of the electrical resistance of complex oxide materials by external stimuli has attracted considerable attention due to potential application in resistive random access memories (RRAM), which can overcome the scaling limitations of memory devices based on charge storage.^{1–3} The underlying physical mechanisms of resistive switching (RS) in complex oxides are manifold and, depending upon the type of material, electrodes, voltage range, and environmental conditions, may involve formation of the conducting filaments, interface Schottky barrier modulation, ion migration, and electrochemical redox reactions.^{4,5} Recently demonstrated resistive switching, tunneling electroresistance (TER) effect, in ferroelectric tunnel junctions (FTJs) is based on a pure electronic mechanism associated with a change in transmission probability of the tunneling electrons upon polarization reversal due to the modification of the tunneling barrier profile.^{6–8} Conventional FTJs exhibit a uniform resistance change over its working area giving rise to a bistable resistance device. On the other hand, resistive switching associated with the chemical or structural disorder in the ferroelectric barrier is highly localized. These local defects could play an important role in the resistive switching of the FTJs by affecting the electron tunneling

process thereby allowing a variable resistance change. Investigation of an interplay between these two mechanisms is of great importance as it may allow significant enhancement of the FTJs functional performance.

A prototypical perovskite SrTiO₃ (STO) is one of the best-studied complex oxide materials exhibiting resistive switching and can be considered as a model system for investigation of this phenomenon. It has been proposed that in STO this effect is due to the electrically induced variations in oxygen concentration along the extended defects, such as dislocations, leading to a formation of conducting filaments.⁹ Recently, emergence of room-temperature ferroelectricity in strain-free ultrathin SrTiO₃ films has been reported.¹⁰ In Sr-deficient STO films, the antisite Ti_{Sr} defects (where Ti substitutes Sr) form during growth inducing a sizable local dipole moment by an off-centering displacement and coherently polarizing the surrounding regions. These Ti_{Sr} antisite defects are also known to produce localized states in the band gap of SrTiO₃.^{11,12} Such

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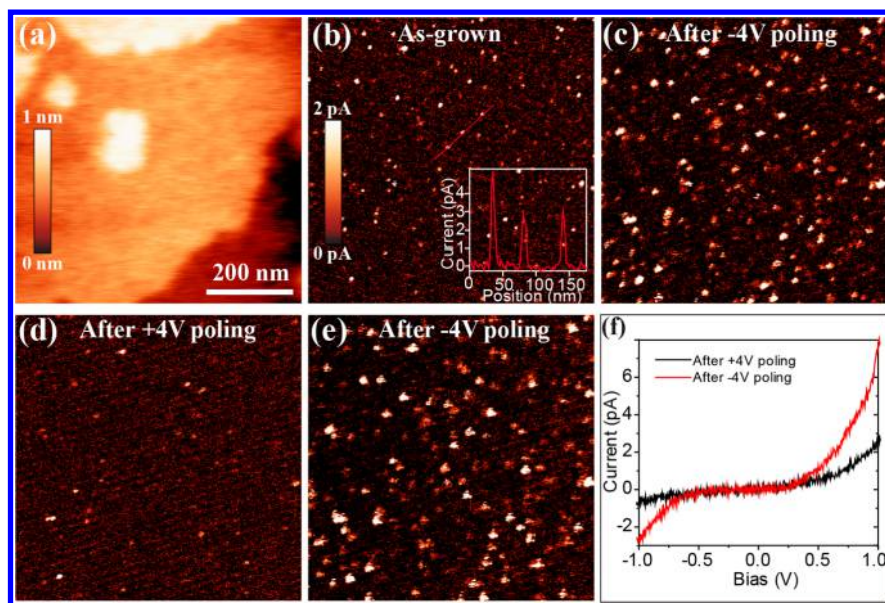


Figure 1. C-AFM mapping of the 12 u.c. thick SrTiO₃ film. (a) An AFM image of the surface topography. (b) C-AFM image of the same area of the as-grown SrTiO₃ film as in (a) showing randomly scattered conducting paths (“hot spots”). An inset in (b) shows a cross-sectional current profile along the red line revealing a lateral dimension of the “hot spots” of about 10 nm. (c–e) C-AFM images of the same film area after (c) –4 V poling, (d) after +4 V poling, and (e) after –4 V poling again. The “hot spots” appear at the same locations upon repeated application of a positive bias. (f) The *I–V* characteristics measured at the same conductive path after ± 4 V poling.

localized states may influence currents across the ultrathin STO films through the mechanism of resonant tunneling, where the transmission coefficient peaks at the energy of the localized state.¹³ Unlike in the case of direct tunneling in the conventional FTJs with a spatially uniform barrier, resonant tunneling probability relies on the distribution of the defect states in the barrier.

In this paper, we investigate the defect-assisted electro-resistance effect in strain-free ferroelectric SrTiO₃ thin films. A combination of conductive atomic force microscopy (C-AFM) and piezoresponse force microscopy (PFM) has been used to map spatial variations in electrical current along with measurements of the local current–voltage characteristics as a function of the film polarization state. It has been found that the transport properties of the local conducting paths, “hot spots”, formed by the Ti_{5r} antisite defects widely present in the SrTiO₃ films, can be modulated by ferroelectric polarization switching induced both by electrical fields and mechanical forces. Our finding indicates that defect-assisted tunneling may play an important role in predicting the properties of the FTJs and designing the resistive switching devices with improved functionality.

In this study, we have used ultrathin strain-free SrTiO₃ films with a thickness of 12 unit cells (u.c.) (~ 4.8 nm) epitaxially grown by pulsed laser deposition (PLD) on the (001) SrTiO₃ substrates with an SrRuO₃ buffer layer as a bottom electrode. Details of the sample preparation method can be found in [Materials and Methods](#). [Figure 1a,b](#) shows high-resolution topographic and C-AFM images, respectively, of the as-grown SrTiO₃ film. The C-AFM image reveals a number of randomly distributed bright spots of about 10–20 nm in size that are not correlated with surface topography. These bright spots correspond to the conducting paths (“hot spots”) with a typical current level of a few pA at 1 V bias (inset in [Figure 1b](#)), while the background shows a current level below a noise level (~ 0.2 pA). Noteworthy, the density of hot spots and the

estimated current density decreases exponentially as the film thickness increases (there are almost no detectable conducting paths in the films with thicknesses above 36 u.c. (see [Figures S1 and S2 in Supporting Information](#))), giving a strong indication of the tunneling conduction mechanism.

To investigate the effect of polarization on the resistive properties of the SrTiO₃ films, we performed the electrical poling to the downward (or upward) polarization state by scanning the film surface with +4 V (or –4 V) dc bias applied to the tip followed by C-AFM imaging of the poled regions. The C-AFM images in [Figure 1c,d](#) corresponds to the current maps for the downward and upward polarized domains, respectively. It can be seen that the region polarized downward exhibits a much larger number of the hot spots ([Figure 1c](#)) than the region polarized upward ([Figure 1d](#)). Furthermore, these changes are completely reversible and reproducible, that is, repeated application of the positive bias to the film polarized upward leads to the appearance of conducting paths at the very same locations ([Figure 1f](#)), indicating that the hot spots are related to the local immobile defects. Interestingly, polarization reversal leads not only to a significant change in the distribution density of the hot spots but also to their brightness, indicating a change in their conductivity. This effect is evident from the current–voltage (*I–V*) curves for opposite polarization states obtained at the same hot spots ([Figure 1f](#)). We note that the resistance change of the surrounding matrix upon polarization reversal is much smaller than that at the hot spots (see [Figure S3 in Supporting Information](#)) due to a small value of polarization in the SrTiO₃ films.¹⁰ In view of this drastically different behavior, the *I–V* curves obtained with the probing tip in contact with the top Pt/Co electrode, which shows a clear signature of the resistive switching effect, should be attributed to the predominant contribution of the a number of hot spots ([Figure S3 in Supporting Information](#)). This integral effect allows detection of resistive switching in the Pt/Co/SrTiO₃/SrRuO₃ junctions even in the low voltage range (below 0.3 V),

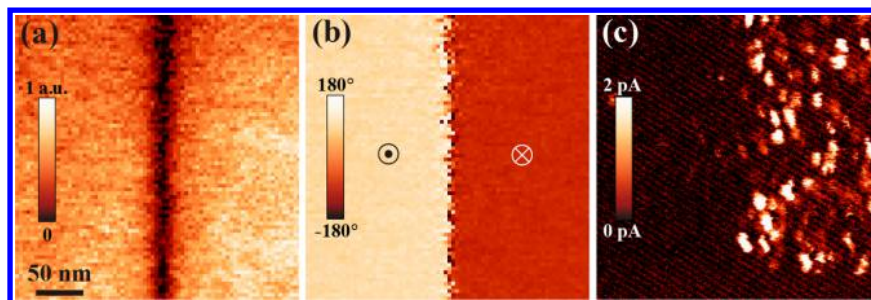


Figure 2. High-resolution PFM and C-AFM imaging on the bipolar domain pattern of the 12 u.c. thick SrTiO₃ film. (a) PFM amplitude, (b) PFM phase, and (c) C-AFM images of the bipolar domains generated by scanning the film surface with a tip under ± 4 V bias (left half polarized up; right half down). It can be seen that the conductivity of hot spots is modulated by electrical poling.

which is not possible for an individual hot spot due to system sensitivity limitation (Figure 1f).

Figure 2 presents a more direct illustration of the relationship between the polarization state and electrical resistance of the SrTiO₃ films. High-resolution PFM images of a bipolar domain structure generated by ± 4 V poling reveal uniform amplitude and phase contrast on both sides across the 180° domain wall whereas the corresponding C-AFM image (Figure 2c) shows a completely different pattern: there are randomly scattered “hot spots” in the downward domain area and noise-level variations of the current in the upward domain.

Our earlier results obtained for the same SrTiO₃ films showed that a minute amount of Sr deficiency (~ 1 atomic %) present in those films could generate polar nanoregions (PNRs) without compromising crystalline quality of the films and give rise to the stable room-temperature ferroelectric state.¹⁰ The ferroelectricity is driven by the Ti_{iSr} antisite defects, which produce a polar displacement between Ti and O ions polarizing the surrounding region. Here, we argue that the same type of defects may lead to the appearance of the observed hot spots with higher conductance than the surrounding matrix. Specifically, the localized states generated by the Ti_{iSr} antisite defects may lead to defect-assisted tunneling enhancement. If such states are randomly distributed over the tunneling barrier, the conductance distribution will appear in the form of scattered hot spots associated with the resonant states in the barrier.^{14,15} Even more importantly, if the barrier layer is ferroelectric the energy position of the localized states shifts with respect to the Fermi level due to the depolarizing field. Thus, polarization reversal is expected to change the resonant transmission amplitude and, hence, the conductance of a hot spot.

To elaborate on this scenario, we performed theoretical modeling (i) to demonstrate the formation of the localized Ti_{iSr} antisite defect states in the band gap of SrTiO₃ in a representative FTJ structure, (ii) to analyze the effect of ferroelectric polarization on the energy position of these states; and (iii) to illustrate the role of hot spots in the polarization-dependent conductance resulting from resonant tunneling through the localized defect states.

In addressing (i), we carried out the density-functional-theory (DFT) calculations (see Materials and Methods for details) using a 5 u.c. thick SrTiO₃ (001) layer with Ti_{iSr} defects in it, as shown in Figure 3 (top and bottom panels). The SrTiO₃ was placed between two metal (Pt) layers, which modeled the bottom electrode and the tip in our experimental conditions. To emulate the asymmetry of the structures tested experimentally, we introduced asymmetry through the asym-

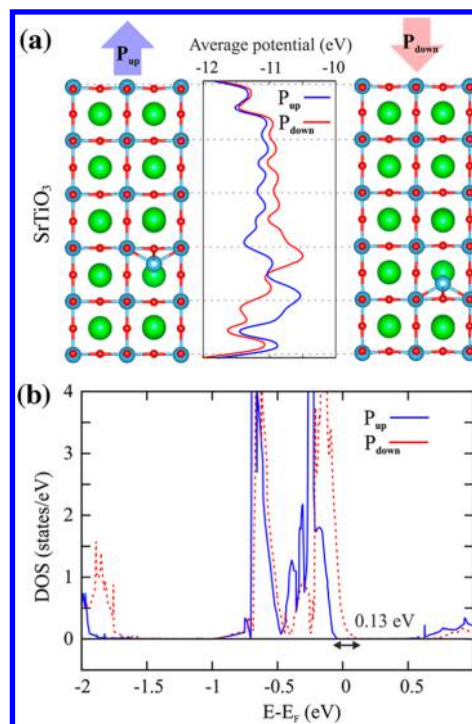


Figure 3. Results of first-principles calculations of ferroelectric SrTiO₃ with a Ti_{iSr} defect. (a) Atomic structure of SrTiO₃ (001) and the electrostatic potential profile for opposite polarization states (P_{up} and P_{down}) with the SrTiO₃ layer is placed between two metal (Pt) electrodes. (b) Local density of states showing a shift of the Ti_{iSr} defect state depending on the polarization state.

metrical placement of the antisite defects. Asymmetric position of the Ti_{iSr} defect state in the SrTiO₃ layer provides asymmetry in the electrostatic potential energy profile (middle panel in Figure 3a). Polarization reversal is associated with the switching of the electrical dipole intrinsic to the Ti_{iSr} defect, resulting in the reversal of the electrostatic potential step at the defect position in SrTiO₃. Analysis of the electronic structure based on the layer-resolved density of states (DOS) shows the presence of the localized states below the conduction band minimum of SrTiO₃ (Figure 3b) consistent with the previous theoretical calculations.^{11,12} The observed two peaks in the DOS of the gap states are associated with the t_{2g} - e_g splitting of the Ti-3d orbitals hybridized with the O-p orbitals on the Ti_{iSr} defect site. The presence of such defect states positioned close to the Fermi energy is expected to assist the conductance through a resonant tunneling mechanism. With respect to (ii) above, from Figure 3b it is evident that, depending on polarization direction,

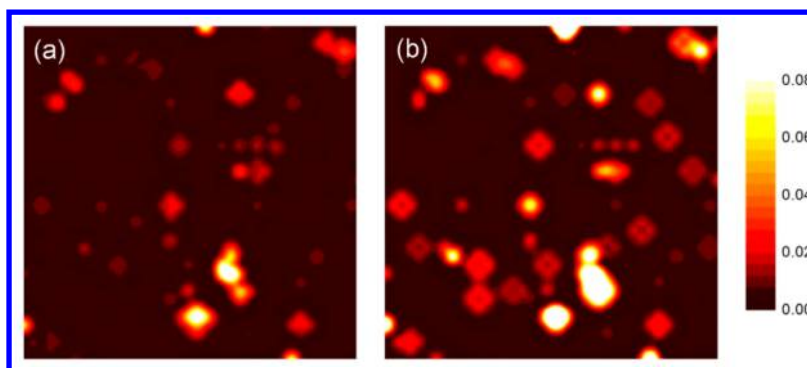


Figure 4. Polarization-dependent tunneling transmission distribution in the SrTiO₃ film with (a) upward, and (b) downward polarization states calculated using a tight-binding model on a 40 × 40 transverse lattice with random distribution of defects.

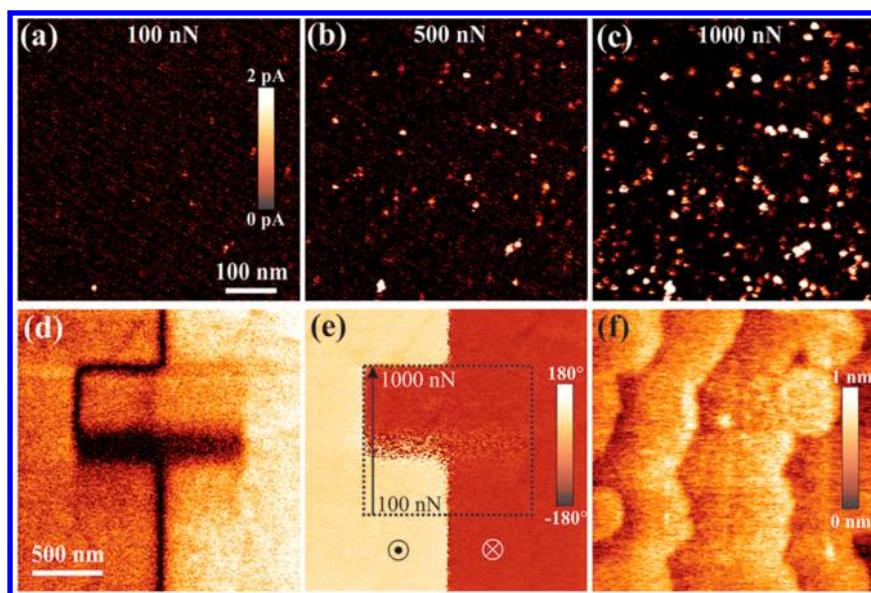


Figure 5. Mechanical control of the “hot spots” density and conductivity in the 12 u.c. thick SrTiO₃ film. (a–c) C-AFM images acquired while scanning the film with the tip under (a) 100, (b) 500, and (c) 1000 nN mechanical load. A density of the “hot spots” increases with increase in the mechanical load. (d,e) PFM amplitude (d) and phase (e) images of a bipolar domain structure where the central 1 × 1 μm² area (marked with a dashed square in (e)) has been mechanically switched. The mechanical load was increased from 100 to 1000 nN in the bottom-up direction. (f) AFM topographic image acquired after mechanical switching showing no surface damage.

the defects states shift in energy. For the P_{up} polarization direction, the defect state lies below the Fermi energy, whereas for the P_{down} polarization direction, this state shifts up in energy by about 0.13 eV and overlaps the Fermi energy. A higher conductance is, therefore, expected in the latter case due to resonant tunneling.

We note that asymmetry in the conductance for opposite polarization directions can be caused not only by the position of the defects states but also by the presence of an intrinsic electric field in the FTJs due to the different work functions of the two electrodes. In this case, the Ti_{5s} defect states in SrTiO₃ near one interface are closer to the Fermi energy than the defect states near an opposite interface. In order to capture this behavior and address (iii) above, we performed tight-binding calculations of the conductance distribution over a thin ferroelectric insulating barrier layer placed on a semi-infinite metal electrode. The electronic structure of the metal and the ferroelectric with defects was designed to qualitatively reproduce the results of our first-principles modeling (see [Materials and Methods](#) for details). [Figure 4](#) shows representative results for the transmission distribution for the

upward and downward polarization states of the ferroelectric barrier. Out of several randomly distributed defects states only those close to Fermi level lead to high transmission, resulting in hot spots. Conductivity of these hot spots is polarization-dependent as the electrostatic potential for the downward (upward) polarization shifts the defect states closer to (farther from) the Fermi energy. As a result, the transmission for the upward polarization is suppressed ([Figure 4a](#)) while transmission for the downward polarization is enhanced ([Figure 4b](#)). This behavior is qualitatively similar to our experimental observations, indicating that the resonant tunneling mechanism associated with the intrinsic defects in SrTiO₃ is responsible for the polarization-dependent hot spot pattern of the conductance distribution. We note that the presence of localized states in the barrier layer may lead to the nonlinear I – V characteristics due to resonant tunneling similar to those seen in [Figure 1f](#).

We also found that in addition to the electrical control, resistive switching of the conductive channels in SrTiO₃ could be tuned by application of the mechanical force. The advantage of this approach is that it alleviates problems associated with the electrochemical modification of the surface and induced

conductivity due to filament formation. A set of the C-AFM images in Figure 5a–c obtained by scanning the SrTiO₃ film with the tip under different mechanical loads during imaging clearly demonstrate that an increasing tip-induced pressure generates a larger density of hot spots and also makes them more conducting. The induced conductive paths remain intact even after the mechanical load is released (Figure S4 in Supporting Information). This phenomenon can be explained by mechanically induced polarization switching in the SrTiO₃ films due to the flexoelectric effect resulting from the tip-induced stress gradient.^{16–18} The PFM images illustrating the mechanical switching of polarization, which were acquired after mechanical scanning, are shown in Figure 5d,e. It can be seen that scanning over a $1 \times 1 \mu\text{m}^2$ area of the bipolar domain structure with the electrically grounded AFM tip under an incrementally increasing load (from 100 to 1000 nN) leads to an inversion of the PFM phase contrast in the left half of the image in Figure 5e from bright to dark at a load of about 500 nN indicating reversal of the polarization from up to down. Note that the film surface did not exhibit any sign of permanent damage after scanning with high mechanical load (Figure 5f). Phase-field simulations confirm the flexoelectric mechanism of mechanically induced switching of the polar nanoregions (PNRs) existing in the SrTiO₃ films (Figure S5 in Supporting Information).

The proposed mechanism of resistive switching in thin films of SrTiO₃ is different from that previously reported for bulk SrTiO₃ single crystals,⁹ where the filamentary conduction occurs due to local modulations of the oxygen content. The magnitude of current in hot spots observed here for 12 u.c. thick films of SrTiO₃ is smaller by a factor of 10^3 than the current reported in the bulk SrTiO₃ single crystals.⁹ Furthermore, our C-AFM data show that both the hot spot density and the current density decrease exponentially with increasing SrTiO₃ film thickness (Figure S1), which is not expected for bulk samples. This behavior is consistent with the results of our tight-binding modeling, which assumes a random distribution of point defects over the volume of an insulating layer serving as a barrier between the tip and the bottom electrode (Figure S2). Also, mechanically induced resistive switching is a voltage-free process, which excludes the electrochemistry-mediated mechanism of conduction enhancement, such as the formation of conducting filaments. All this evidence suggests that defect-assisted tunneling mechanism, where the conduction is dominated by “hopping” through a defect state,¹⁵ plays a decisive role in thin film SrTiO₃ samples. Our experimental and theoretical results showing the polarization-dependent conductance of the hot spots (Figures 1–4) are consistent with the polar defect nature of the ferroelectric polarization in SrTiO₃. Although other kinds of nonpolar defects in SrTiO₃,^{11,12} such as oxygen vacancies, may also contribute to the conduction, the effect of ferroelectric polarization on their energy position is likely to be weaker.

Overall, our results demonstrate that the resistive switching behavior of the strain-free ultrathin SrTiO₃ films is controlled by the formation of the conducting paths, hot spots, at the locations of the Ti_{Sr} antisite defects, which are also responsible for the appearance of polar nanoregions and emergence of the net ferroelectric polarization. We suggest that the origin of the hot spots is resonant tunneling through the localized electronic states created in the band gap of SrTiO₃ due to the Ti_{Sr} antisite defects. Additional measurements may be necessary to corroborate this mechanism. It is shown that the energy

position of the localized defect states can be modulated by ferroelectric polarization, leading to the polarization-dependent conductance of the hot spots. Polarization-controlled defect-assisted tunneling manifests a new mechanism of resistive switching in oxide heterostructures. In addition, the conductivity of the hot spots can be modulated by mechanical stress, opening a possibility for development of conceptually new electronic devices with mechanically tunable resistive states.

Materials and Methods. *Thin Film Growth.* Strain-free SrTiO₃ epitaxial thin films were grown on (001) SrTiO₃ substrate using the pulsed laser deposition (PLD) method.¹⁹ Before deposition, low miscut ($<0.05^\circ$) SrTiO₃ substrates were etched with a buffered hydrofluoric acid for 1 min and annealed in oxygen at 1050 °C for 6 h to create atomically smooth single TiO₂-terminated surfaces with unit cell steps. A SrRuO₃ layer with a thickness of 10–15 nm was deposited as a bottom electrode on the SrTiO₃ substrate. A KrF excimer laser (248 nm) beam was focused on stoichiometric SrRuO₃ ceramic and SrTiO₃ single-crystal targets to an energy density of $\sim 2.0 \text{ J/cm}^2$ and pulsed at 3–5 Hz. SrTiO₃ films were grown at a substrate temperature of 750 °C and oxygen partial pressures of 10 mTorr. The PLD system was equipped with high-pressure reflection high-energy electron diffraction, which enabled atomic layer controlled growth and in situ monitoring during the growth. After growth, the films were slowly cooled to room temperature in 1 atm of oxygen.

PFM and C-AFM Imaging. PFM and C-AFM measurements were performed using a commercial AFM system (Asylum Research, MFP3D). Pt-coated Si tips (PPP-EFM, Nanosensors) were used for PFM and C-AFM imaging. For PFM imaging, a resonant-enhanced mode was used with resonance frequency around 350 kHz and ac modulation amplitude of 0.3 V. For C-AFM imaging, a constant dc bias of 1 V was applied to the bottom electrode, whereas the tip was grounded. The resolution for measured current was around 0.1 pA.

Density Functional Theory Calculations. Density functional theory (DFT) calculations were performed using a model system of a periodic 2×2 supercell of Pt/(SrTiO₃)₅/Pt (001) with a single Ti_{Sr} defect. For simplicity, we assumed identical Pt electrodes and an energetically favorable TiO₂ interface termination of the SrTiO₃. The in-plane lattice constant of the supercell was constrained to the bulk lattice constant of SrTiO₃, $a = 3.903 \text{ \AA}$. The atomic and electronic structure of the system was calculated using the plane-wave DFT methodology as implemented in the Vienna Ab Initio Simulation Package (VASP) code.²⁰ We employed the Perdew–Burke–Ernzerhof (PBE) exchange–correlation functional²¹ in the modified form for solids (PBEsol)²² within the generalized gradient approximation (GGA) in combination with the projector augmented wave (PAW) potentials.²³ On-site electron–electron Coulomb interactions of the Ti-3d states were treated within the GGA + U approach with $U_{\text{eff}} = 4.36 \text{ eV}$. Calculations were carried out using plane-wave basis set with a cutoff kinetic energy of 400 eV and $6 \times 6 \times 1$ mesh of k points in the irreducible Brillouin zone until the total energy was converged to within 0.01 meV per cell. Atomic relaxations were performed until the Hellmann–Feynman forces on atoms were less than 20 meV/Å.

Tight-Binding Modeling. The transmission coefficient was calculated using the tight-binding (TB) Green’s function technique.²⁴ A single-band TB model on a cubic lattice with a nearest-neighbor hopping parameter t was used in the

calculations (a representative value of t is 1 eV). The top “scanning-probe” electrode was modeled by the 1D atomic chain with on-site energy $\varepsilon_L = -t$. The insulating barrier layer and the bottom electrode had a finite cross section of $N_x \times N_y$ sites. The on-site atomic energies of the insulating layer, the defect atoms, and the bottom electrode were taken to be $\varepsilon_B = 6.5t$, $\varepsilon_D = -5.88t$, and $\varepsilon_R = 3.0t$, respectively. The Fermi energy was assumed to be $E_F = 0$. These parameters place the conduction band minimum $3t$ below E_F for the bottom and top electrodes and $0.5t$ above E_F for the insulator. The resulting resonant state appears at about $-0.5t$ (which is consistent with our first-principles results for $t = 1$ eV). The intrinsic potential drop due to the difference in the work functions of the electrodes, ΔU , and the potential drop due to the ferroelectric polarization ΔV_p are considered as parameters. In particular calculations shown in Figure 4, they are assumed to be $\Delta U = 0.25t$ and $\Delta V_p = \pm 0.2t$. Other parameters used in this calculation are as follows: $N_x = N_y = 40$ u.c. and insulator layer thickness is $d = 4$ u.c. Ten percent of defect states were considered to be randomly distributed within the ferroelectric barrier layer.

Phase-Field Modeling. The phase-field model for SrTiO₃ (STO) films with polar nanoregions (PNR) follows our previous work.¹⁰ The temporal evolution of polarization is described by the time-dependent Ginzburg–Landau (TDGL) equation, that is

$$\frac{\partial P(x, t)}{\partial t} = -L \frac{\delta F}{\delta P(x, t)}$$

where $P(x, t)$ is the polarization at position x at time step t , F is the total free energy density and L is the kinetic coefficient related to domain wall mobility. The bulk, elastic, electric, flexoelectric, and gradient energy contributions are considered in the total free energy F , which is expressed as

$$F = \iiint_V [f_{\text{Bulk}}(P_i) + f_{\text{Electric}}(P_i, E_i) + f_{\text{Elastic}}(P_i, \varepsilon_{ij}) + f_{\text{Flexo}}(P_i, \varepsilon_{ij}) + f_{\text{gradient}}(P_{i,j})] dx^3$$

The detailed expression for each term is elucidated in our previous works.^{25–27} The parameters used in the total free energy of STO in this work are the same as Li et al’s work²⁸ and the flexocoupling coefficients from Zubko et al’s measurements,^{29,30} that is, $f_{11} = 0.08$ V, $f_{12} = 2.6$ V, and $f_{44} = 2.2$ V. For the PNR region of STO, the coefficients in the Landau bulk energy is modified to fit the equilibrium polarization along $\{001\}$ as ~ 0.1 C/m² calculated by previous DFT calculations.¹⁰ The PNR is set to be at the center of STO film with a spherical shape of 15 nm in diameter.

To solve the three-dimensional TDGL equation of polarization, the system is discretized into $128\Delta x \times 128\Delta x \times 40\Delta x$ with grid size $\Delta x = 0.39$ nm. Semi-implicit Fourier transformation method is used.³¹ Periodical boundaries are assumed laterally and the lateral size is chosen to be large enough to eliminate the interactions between PNR with its images. Along the x_3 direction, the system is divided into substrate, film and air in the, where each part takes up 20, 12, and 8 Δx , respectively. A free boundary condition, that is, $\frac{\partial P_3}{\partial x_3} = 0$, is assumed for polarization. The routines for solving the elastic and electric equations were well described in refs 25 and 26. To mimic the probe force, a hyperbolic tangent function is assumed to approximate the stress distribution on the film

surface and superimposed on the stress-free boundary condition at the top surface. The short circuit electric boundary condition is adopted for both top and bottom interfaces to represent a fully compensated film. The system is first poled by 1 V bias from a uniform top electrode for enough long time to reach equilibrium. Then it is subjected to an incremental mechanical force imposed at the center of PNR region on the film surface. The loading forces increase from 200 up to 1000 nN with an increment of 100 nN/2000 timesteps. Finally the force is removed and the system is let to relax to the equilibrium.

■ ASSOCIATED CONTENT

📄 Supporting Information

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Additional information, figures, and refs (PDF)

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Author Contributions

H.L. and D.L. contributed equally to the project. H.L., D.L., E.Y.T., C.B.E., and A.G. designed the research. H.L. carried out the PFM and C-AFM measurements; D.L., H.L., and J. L. fabricated thin film samples; K.K., L.T., T.R.P., E.Y.T., and V.A. performed DFT calculations and tight-binding calculations; B.W. and L.Q.C. performed phase-field modeling. All the authors contributed to the manuscript preparation.

Notes

The authors declare no competing financial interest.

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